



Product Overview

Focus Tech DV-6400

Developer Concentrate

Product Description

DV-6400 is a concentrated developer solution designed for use in photoresist and soldermask developing processes. Formulated using water softening agents, working solutions of DV-6400 can be made using tap water with up to 400 ppm's of dissolved solids without forming significant hardness scale. DV-6400 also contains cleaning compounds that help break up resist residues and minimize build up in the process and control equipment. The Focus Tech developing system combines high quality with ease of use to provide a superior developing system.

Features

- ⊙ Na₂CO₃/K₂CO₃ formulation
- ⊙ Softening agents
- ⊙ Detergent additives

Benefits

- ⊙ Minimizes operating cost
- ⊙ Eliminates need for purified water
- ⊙ Extends uptime by slowing residue build-up

Physical Properties

Concentration:	400 g/L as potassium carbonate
Specific gravity:	1.30
pH:	>12
Appearance:	clear, water white
Freezing point:	<40 °F

Operating Parameters

Make Up:	2.0 – 2.5% v/v DV-6400 8 – 10 g/L as potassium carbonate
Replenishment:	2.0 – 2.5% v/v DV-6400 8 – 10 g/L as potassium carbonate
Process pH:	10.4 – 10.9
Temperature:	80 °F – 90 °F

Storage

Store in original containers above 40 °F.

Safety

CAUTION! DV-6400 concentrates and working solutions contain strong alkaline ingredients. Avoid contact with eyes, skin and clothing. Wear chemical handler's gloves, goggles and protective clothing when handling. Read and understand Material Safety Data Sheet before using this product.

Notice

The information and recommendations, contained herein, regarding this product are, to the best of our knowledge, true and accurate. We make no guarantee of results because the conditions of actual use are beyond our control. We assume no liability for damages or penalties resulting from the use of this product or following our recommendations. Our recommendations and suggestions for use of this product are not intended to grant license to operate under or infringe any patent.